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(54) Title: DISTRIBUTION SYSTEM FOR A PROCESS FLUID AND ELECTRIC CURRENT FOR CHEMICAL AND/OR ELEC-
TROLYTIC SURFACE TREATMENT OF A SUBSTRATE

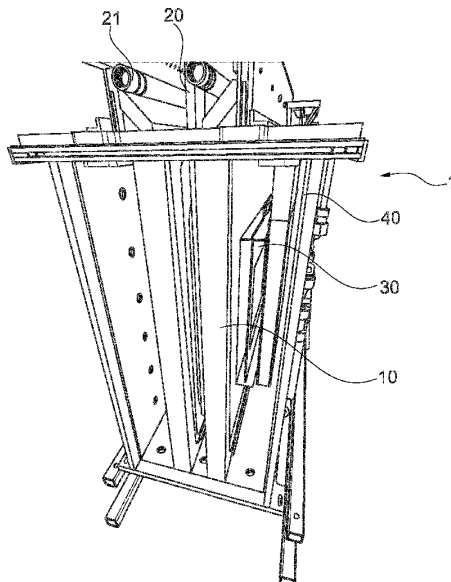


Fig. 1

(57) Abstract: The invention relates to a distribution system for a process fluid for chemical and/or electrolytic surface treatment of a substrate, a distribution method for a process fluid for chemical and/or electrolytic surface treatment of a substrate and a data processing device. The distribution system for a process fluid for chemical and/or electrolytic surface treatment of a substrate comprises a distribution body and a shield element. The distribution body comprises a plurality of openings for the process fluid. The shield element is configured to at least partially cover at least one of the plurality of openings to limit a flow of the process fluid through the distribution body.

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